U.S. Patent Application Serial No. 09/995,802

Attorney Docket No.: 011606

light emitting element 14, first heat sink 11 and second heat sink 12 are brought into contact with each other before pressure is applied for example from the top of the first heat sink 11 and the solder

material 15, 15a, 15b, 15c, and 15d is heated to melt. This readily cancels the dimensional errors

the semiconductor light emitting element 14, it is always ensured that the solder foil, semiconductor

among the individual components and the element, which results in proper contact between the

semiconductor light emitting element 14, first heat sink 11 and second heat sink 12.

Please replace the paragraphs beginning at page 28, line 16, continuing to page 29, with the following rewritten paragraphs:

As shown in Fig. 1, there is provided a space in the vicinity of the junction of the first heat sink 11 and the second heat sink 12, into which excess solder material 15b can preferably flow to thereby prevent such adhesive from reaching the semiconductor light emitting element 14. More specifically, it is preferable to provide this space with no passage to the semiconductor light emitting element 14, so that excess solder 15b will flow into this space and there remain.

As described in the above, the thickness of the semiconductor light emitting element and thickness of the heat sink intrinsically are prone to dimensional errors, so that the mounting as illustrated in Fig. 1, in which the semiconductor light emitting element 14, first heat sink 11 and second heat sink 12 are kept in parallel with each other, needs some mechanism by which differences of the thickness among the relevant components can be compensated for, and such relevant components can be integrated. For such purpose, it is beneficial that the thickness of the solder

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material 15b is intentionally selected to be thick enough to absorb dimensional errors in the

individual components, and that a certain space is provided in order to accumulate the excess, solder

at a remove from the semiconductor light emitting element 14 so as to keep it contacting with the

element. In the embodiment shown in Fig. 1, the solder foil is initially mounted on portion A, which

is a part of the second heat sink, and is then melted under heating for the joining of the first heat sink

11, second heat sink 12 and semiconductor light emitting element 14, where a part of the solder foil

flows into portion B of the second head sink 12. Such space for accommodating the solder 15b may

be recesses in the second heat sink 12, or may be recesses in the first heat sink 11, or may be recesses

in both. While there is no limitation on the shape of the recesses, the shape is preferably such that

it allows smooth flow of the solder therein and prevents reverse flow. Providing the recesses at least

on a part of the second heat sink 12 is particularly preferable.

While such structural approach of providing for the solder pool is of course effective in

preventing contact of the solder with the semiconductor light emitting element 14, it is also

allowable to intentionally provide on a part of the heat sink a portion capable of reducing wetting

(affinity) of the solder to thereby prevent the solder 15b for joining the first and second heat sinks

11,12 from flowing into the portion where the semiconductor light emitting element 14 is to be

mounted.

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Please replace the paragraphs beginning at page 29, line 34, continuing to page 30, with the

following rewritten paragraphs:

The wetting (affinity) improving layer is located so as to enhance the flow of the excessive solder into the space for accommodating the solder. In particular, it is preferable to locate such layer so that the solder material **15b** will surely flow into the space while preventing flow towards the semiconductor light emitting element **14**. Specific embodiments thereof can be exemplified as those shown in Figs. 5A to 5D, other than that shown in Fig. 1. In a structure shown in Fig. 5A, the wetting affinity improving layer is placed on a slope so that the excessive solder material **15b** can flow down leftward in the figure. In such case, the wetting (affinity) improving layer is definitely not provided in the vicinity of the top end portion of the slope, which is close to the semiconductor light emitting element **14**, so that the solder material **15b** will not flow towards the semiconductor light emitting element **14**. Also in structures shown in Figs. 5B to 5C, the device is composed so that the excessive solder material **15b** accumulates in a portion where the wetting (affinity) improving layer is formed, or flow over such portion to drop in the solder pool. Such structure may be provided in a plural number per heat sink. In such case, the individual structures may differ from each other.

In the present invention, it is preferable that at least a part of the electrode for the first-conduction-type semiconductor is in contact with the first heat sink as being interposed with a first adhesive 15a (preferably solder material); at least a part of the first heat sink is in contact with the second heat sink interposed with a second adhesive 15b (preferably solder material); and the total

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(Short

weight of the second adhesive 15b is twice or more, and more preferably five times or more, heavier than the total weight of the first adhesive 15a. Providing such difference in the weight of the adhesives is advantageous in that facilitating the adjustment of the semiconductor light emitting element, first heat sink and second heat sink, which should be set in parallel with each other, during the assembly.

Please replace the paragraphs beginning at page 34, line 31, continuing to page 35, with the following rewritten paragraphs:

An AlN sub-mount, having no electro-conductivity in the direction of thickness, was

procured as the second heat sink 12. The second heat sink 12 is preliminarily evaporated with a Ti/Pt/Au layer 16 on a wetting (affinity) improving layer 19, laser mounting surface and surfaces parallel thereto in order to ensure only the conductivity within the surface, where only the laser mounting portion was further evaporated with an AuSn solder 15c so as to be stacked on the Ti/Pt/Au layer 16. On the other hand, an AlN sub-mount, which is entirely covered with a Ti/Pt/Au layer 16 so as to ensure the electro-conductivity in the direction of thickness, was prepared as the first heat sink 11, where over the entire laser mounting portion an AuSn solder layer 15a was further

First, the semiconductor light emitting element 14 was mounted on the second heat sink 12 under the normal temperature so as to allow the n-side electrode thereof to contact with the second heat sink 12 while aligning the edge of the second heat sink 12 and the front facet of the element 14;

formed by evaporation on the Ti/Pt/Au layer 16.

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an AuSn solder layer of 85 µm thick is then placed on the wetting (affinity) improving layer 19; the first heat sink 11 is positioned so that the edge thereof is recessed by 25 µm to the rear of the facet of the semiconductor laser element 14 as shown in Fig. 2; mounted to be in contact with the AuSn solder layer 85 µm thick and with a part of the p-side electrode; the temperature was raised to 290 under 30 g load, to thereby join the first heat sink 11, second heat sink 12 and semiconductor laser element 14 to complete a COS, the semiconductor light emitting device. In such process, excess AuSn solder was found to flow from the portions contacting the first heat sink 11 and second heat sink 12 into the area removed from both. A stem containing CuW for current injection was then prepared as a third heat sink 13, and the COS was then joined therewith again using the AuSn solder 15d so as to allow the bottom plane of the second heat sink 12 to contact with such third heat sink 13. Thereafter, the portion of the first heat sink 11 covered with the Ti/Pt/Au layer 16 was bonded with three gold wires 17 of 25 µm diameter by ultrasonic fusion process to thereby produce the pside electrode, and the second heat sink 12 covered with the Ti/Pt/Au layer 16 was also bonded with three gold wires 18 of 25 µm diameter by ultrasonic fusion process to thereby produce the n-side electrode to allow current injection. The entire structure was sealed in a nitrogen atmosphere to be completed as a can package.